



Receipt  
JC05 Rec'd PCT/PTO 01 AUG 2001  
PATENT APPLICATION

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

#51

In re the Application of

Shouji YAJIMA et al.

Application No.: 09/806,236

Docket No.: 109067

Filed: March 28, 2001

RECEIVED

NOV 21 2001

TC 1700

For: PRODUCTION OF SYNTHETIC SILICA GLASS AND THERMAL TREATMENT  
APPARATUS

**REQUEST FOR CORRECTION OF PALM RECORDS**

Director of the U.S. Patent and Trademark Office  
Washington, D.C. 20231

Sir:

Attached is a photocopy of the original filing receipt on which errors have been corrected in red. These errors are being brought to the attention of the Patent and Trademark Office so that it may correct its records.

Respectfully submitted,

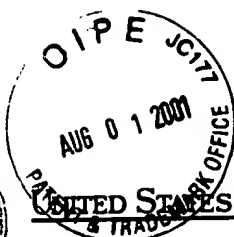
James A. Oliff  
Registration No. 27,075

Joel S. Armstrong  
Registration No. 36,430

Date: August 1, 2001

OLIFF & BERRIDGE, PLC  
P.O. Box 19928  
Alexandria, Virginia 22320  
Telephone: (703) 836-6400

|  |
|--|
| DEPOSIT ACCOUNT USE<br>AUTHORIZATION<br>Please grant any extension<br>necessary for entry;<br>Charge any fee due to our<br>Deposit Account No. 15-0461 |
|--|



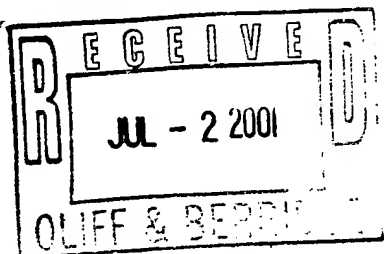
## UNITED STATES PATENT AND TRADEMARK OFFICE

COMMISSIONER FOR PATENTS  
UNITED STATES PATENT AND TRADEMARK OFFICE  
WASHINGTON, D.C. 20231  
www.uspto.gov

CMM

| APPLICATION NUMBER | FILING DATE | GRP ART UNIT | FIL FEE REC'D | ATTY. DOCKET NO | DRAWINGS | TOT CLAIMS | IND CLAIMS |
|--------------------|-------------|--------------|---------------|-----------------|----------|------------|------------|
| 09/806,236         | 03/28/2001  | 1731         | 860           | 109067          | 22       | 6          | 2          |

Oliff & Berridge  
PO Box 19928  
Alexandria, VA 22320



CONFIRMATION NO. 6948

## FILING RECEIPT



\*OC000000006234651\*

Date Mailed: 06/27/2001

Receipt is acknowledged of this nonprovisional Patent Application. It will be considered in its order and you will be notified as to the results of the examination. Be sure to provide the U.S. APPLICATION NUMBER, FILING DATE, NAME OF APPLICANT, and TITLE OF INVENTION when inquiring about this application. Fees transmitted by check or draft are subject to collection. Please verify the accuracy of the data presented on this receipt. If an error is noted on this Filing Receipt, please write to the Office of Initial Patent Examination's Customer Service Center. Please provide a copy of this Filing Receipt with the changes noted thereon. If you received a "Notice to File Missing Parts" for this application, please submit any corrections to this Filing Receipt with your reply to the Notice. When the USPTO processes the reply to the Notice, the USPTO will generate another Filing Receipt incorporating the requested corrections (if appropriate).

NOV 21 2001

## Applicant(s)

Shouji Yajima, Kanagawa-ken, JAPAN;  
Hiroyuki Hiraiwa, Kanagawa-ken, JAPAN;  
Yasuji Ishida, Kanagawa-ken, JAPAN;

Sagamihara-shi.

Yokohama-shi.

Toki-gun

TC 1700

## Domestic Priority data as claimed by applicant

THIS APPLICATION IS A 371 OF PCT/JP00/05412 08/11/2000

Assignment for Published Patent  
Application  
NIKON CORPORATION

## Foreign Applications

JAPAN P1999-228197 08/12/1999

Projected Publication Date: N/A

Non-Publication Request: No

Early Publication Request: No

## Title

Production method

Method for preparation of synthetic vitreous silica glass and apparatus for heat treatment apparatus

## Preliminary Class

065